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ISSUE CLASSIFICATION

PATENT NUMBER

U.S. UTILITY Patent Application

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| O.I.P.E. | PATENT DATE |
| SCANNED <u>15/3</u> Q.A. <u>SM</u> | |

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| APPLICATION NO. | CONT/PRIOR | CLASS 118 | SUBCLASS 778 | ART UNIT 1763 1764 | EXAMINER Collins |
| 09/872203 | | | | | |

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438

1753

EXAMINER W. A. G. Smith

Method of forming a thin film using atomic layer deposition

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PTO-2040
12/99

| TERMINAL DISCLAIMER | DRAWINGS | | | CLAIMS ALLOWED | |
|--|--------------|-------------|------------|-------------------------------------|----------------------|
| | Sheets Drwg. | Figs. Drwg. | Print Fig. | Total Claims | Print Claim for O.G. |
| <input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed. | | | | NOTICE OF ALLOWANCE MAILED | |
| <input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent No. _____ | | | | ISSUE FEE | |
| | | | | Amount Due | Date Paid |
| <input type="checkbox"/> The terminal _____ months of this patent have been disclaimed. | | | | ISSUE BATCH NUMBER | |
| | | | | (Legal Instruments Examiner) (Date) | |

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